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		U.S. PAT	ENT DOCUMENTS				
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FIL. DATE IF APPROP.	
			R DOCUMENTS				
AICS	article entitled, "Polycrystalline silicon thin films formed by metal-induced solid phase crystallization of amorphous silicon", Y. Z. Wang et al., J. Vac. Sci. Technol. A, Vol. 16, No. 6, 1998, pp. 3352-3358.						
AICS	article entitled, "Spectroscoptic ellipsometry investigation of nickel silicode formation by rapid thermal process", Y. Hu et al., J. Vac. Sci. Technol. A, Vol. 16, No. 3, 1998, pp. 1820-1824						
2214	article entitled, "Low Temperature Poly-Si Thin-Film Transistor Fabrication by Meta Induced Lateral Crystallization", S-W Lee et al. IEEE Electron Device Letters, Vol. 1 No. 4, 1996, pp. 160-162.						
EXAMINER As Sh Unwar Sarliar				DATE CONSIDERED 4[1] 02			